Intrinsic high electrical conductivity of stoichiometric SrNbO₃ epitaxial thin films

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SrVO₃ and SrNbO₃ are perovskite-type transition-metal oxides with the same d^1 electronic configuration. Although SrNbO₃ (4 d^1) has a larger d orbital than SrVO₃ (3 d^1), the reported electrical resistivity of SrNbO₃ is much higher than that of SrVO₃, probably owing to nonstoichiometry. In this paper, we grew epitaxial, high-conductivity stoichiometric SrNbO₃ using pulsed laser deposition. The growth temperature strongly affected the Sr/Nb ratio and the oxygen content of the films, and we obtained stoichiometric SrNbO₃ at a very narrow temperature window around 630 °C. The stoichiometric SrNbO₃ epitaxial thin films grew coherently on KTaO₃ (001) substrates with high crystallinity. The room-temperature resistivity of the stoichiometric film was 2.82 × $10^{-5} \Omega$ cm, one order of magnitude lower than the lowest reported value of SrNbO₃ and comparable with that of SrVO₃. We observed a *T*-square dependence of resistivity below $T^* = 180$ K and non-Drude behavior in near-infrared absorption spectroscopy, attributable to the Fermi-liquid nature caused by electron correlation. Analysis of the *T*-square coefficient *A* of resistivity experimentally revealed that the 4*d* orbital of Nb that is larger than the 3*d* ones certainly contributes to the high electrical conduction of SrNbO₃.

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I. INTRODUCTION

Perovskite oxides (ABO_3) have been extensively studied as a platform for systematic research on the electronic states and physical properties of transition-metal oxides (TMOs). A variety of studies have greatly contributed to the theoretical framework for the electronic states of 3*d* TMOs [1–5]. In contrast, the electronic properties of 4*d* TMOs are less understood, except for a few examples, such as ruthenates [6,7]. It is widely accepted that spatially spread *d* orbitals in 4*d* TMOs would cause higher electrical conductivity owing to their stronger hybridization with oxygen and a weaker on-site Coulomb interaction than in 3*d* TMOs with an equivalent electronic configuration. This electronic picture has been supported by systematic studies on the optical conductivity and x-ray absorption of SrMO₃ (M = 3d or 4*d* transition metal) [8,9].

Among the 4*d* perovskite oxides, however, the intrinsic electrical properties of SrNbO₃ (4*d*¹ configuration) have not been revealed. For example, the reported resistivity of SrNbO₃ [10–12] is one order of magnitude higher than that of SrVO₃ [13,14], a 3*d* TMO with the same d^1 configuration as SrNbO₃, which runs contrary to the general expectation that 4*d* TMOs should have a higher conductivity than the 3*d* ones. So far, this phenomenon has yet to be explained.

Investigating the electrical properties of $SrNbO_3$ is difficult because it is hard to avoid Sr deficiencies in bulk samples [15,16], though Sr-deficient bulk samples have recently attracted attention because they exhibit both metallic electrical conduction and photocatalytic activity for visible light [10]. One possible cause for the formation of Sr deficiencies is the high processing temperature, over 1000 °C, which is required for bulk synthesis. This problem could be solved by low-temperature epitaxial growth of SrNbO₃ thin films: For example, Balasubramaniam *et al.* and Tomio *et al.* reported the epitaxial growth of an SrNbO₃ thin film with an almost stoichiometric Sr/Nb ratio by pulsed laser deposition (PLD) at relatively low temperatures of 800 °C [17] and 770 °C [11]. However, the SrTiO₃ substrates used in these two studies might have become conductive under reductive growth conditions, which brings into question the reliability of the SrNbO₃ transport properties, as we will discuss later. Another problem is the large lattice mismatch between SrNbO₃ (a = 4.023 Å in a pseudocubic approximation) and SrTiO₃ (a = 3.905 Å; mismatch = -2.93%), which would degrade the film quality.

In the present study, we grew epitaxial SrNbO₃ thin films on single-crystal KTaO₃ (a = 3.989 Å; mismatch = -0.85%) using PLD. We found that both the oxygen amount and the Sr/Nb ratio of the films strongly depended on the growth temperature. The stoichiometric SrNbO₃ epitaxial thin film grown at an optimized temperature exhibited remarkably high conductivity, comparable with SrVO₃, with the temperature dependence as a Fermi liquid.

II. EXPERIMENT

We grew the films on the (001) plane of KTaO₃ substrates (MTI Corporation) under the background pressure of the growth chamber (< 1×10^{-8} Torr). To deposit the material, a ceramic pellet of Sr₂Nb₂O₇ was ablated by a KrF excimer laser ($\lambda = 248$ nm), operated at an energy fluence of 0.33–0.44 J cm⁻² shot⁻¹ and a repetition rate of 10 Hz. The film thickness was 15–40 nm. The substrate temperature was varied using infrared lamp heating.

The crystal structures of the thin films were examined by x-ray diffraction (XRD) using a four-axis diffractometer (Bruker AXS D8 Discover). The cation composition of the films was evaluated by x-ray photoemission spectroscopy (XPS) and inductively coupled plasma mass spectrometry

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(ICP-MS). Before each XPS measurement, the sample surface was cleaned by Ar ion sputtering. The optical absorption coefficient was obtained from transmittance and reflectance spectra, measured with an ultraviolet-visible near-infrared (NIR) spectrometer. The electrical resistivity, carrier density, and mobility were evaluated by the four-probe method and Hall measurements using a conventional Hall-bar geometry with 100-nm-thick Ag electrodes. Low-temperature measurements were conducted with a physical property measurement system (Quantum Design Model 6000).

III. RESULTS AND DISCUSSION

XRD measurements revealed that every film possessed a tetragonal perovskite structure, epitaxially grown on the KTaO₃ substrate with a cube-on-cube relation. Though the 2θ - θ pattern showed no impurity phase, the films grown at temperatures lower than 600 °C exhibited a streaky diffraction pattern between the 001 and 101 peaks of the perovskite SrNbO₃ in the reciprocal-space image scanned by a twodimensional area detector [Fig. 1(a)]. The 2θ angle of this streak pattern is around 26°, which corresponds well with the strongest 080 reflection of $Sr_2Nb_2O_7$ (a = 3.96 Å, b = 5.71 Å, c = 26.76 Å) [18] while it could not be assigned to other possible compounds such as the Ruddlesden-Popper phase. The χ angle of the streak suggests a (014) orientation of the impurity Sr₂Nb₂O₇, which is the same epitaxial orientation of $La_2Ti_2O_7$ grown on the (100) plane of SrTiO₃ [19]. Because we used an oxygen-rich target (Sr₂Nb₂O₇), excess oxygen layers could be readily formed without introducing oxygen gas. In fact, the streak pattern disappeared at higher growth temperatures, which were more reductive growth conditions [Fig. 1(a)].

While the excess oxygen layer disappeared at higher temperatures, the lattice constant, calculated from 002 and 004 diffractions, decreased as the growth temperature increased above 600 °C [Fig. 1(b)]. This reduction was probably caused by cation off-stoichiometry: An XPS measurement revealed that the Sr/Nb ratio monotonically increased with increasing growth temperature [Fig. 1(c)]. An ICP-MS measurement confirmed that the Sr/Nb ratio of the film grown at 630 °C was 0.96 + 0.10, an essentially stoichiometric value within the experimental error. Because XRD confirmed the phase-pure perovskite structure, even at high growth temperatures, the Sr-rich compounds were likely created by the introduction of an Nb vacancy at the B site or the partial substitution of Sr in the B site [20]. From these results, we conclude that the optimal temperature to grow SrNbO₃ epitaxial thin films is 630 °C. Hereafter we refer to the film grown at the optimal temperature as the stoichiometric SrNbO₃ epitaxial thin film.

We investigated the crystal structure of the stoichiometric SrNbO₃ epitaxial film in more detail using high-resolution XRD. Figure 2(a) shows a high-resolution 2θ - θ pattern of the stoichiometric SrNbO₃ thin film. The fringe pattern evolved around the 002 peak indicates that the film surface and film/substrate interface were both flat [inset of Fig. 2(a)]. Figure 2(b) shows a reciprocal-space map around the 103 peaks of the film and the substrate. The film was coherently grown on the substrate, and the out-of-plane lattice constant was evaluated as 4.07 Å, which indicates compressive epitaxial



FIG. 1. (Color online) (a) Two-dimensional detector images of the SrNbO₃ thin films grown on KTaO₃ single crystals at various temperatures. The tilt angle of the sample (χ) was 45°. The 001 and 101 peaks of the films and substrates overlap with each other. White circles indicate the streaky diffraction patterns from the films. The scale of the color bar representing the intensity is set to make the weak streak pattern clear. The 001 and 101 peaks are displayed with the saturated color, of which counts are over 3000 and 5000, respectively. (b) Out-of-plane lattice constants of the SrNbO₃ films plotted against growth temperature. (c) XPS intensity ratios between the Sr 4*p* and Nb 3*d* peaks of the SrNbO₃ thin films grown at various temperatures. These values are normalized by the photoionization cross section.

strain from the substrate. A rocking curve of the 002 peak had a full width at half maximum as small as 0.04°, indicating that the film had good crystallinity.

Figure 2(c) shows an absorption coefficient spectrum of the stoichiometric $SrNbO_3$ epitaxial thin film, revealing broad absorption in both the visible and NIR regions. A Tauc plot [inset of Fig. 2(c)] was made, assuming an indirect band-toband transition, based on a previous band calculation [10]. The plot shows a dip structure around 2 eV, suggesting an overlap of absorption bands with different origins in the visible and NIR regions. The absorption in the visible region corresponds well to that in Sr-deficient bulk $SrNbO_3$, which has been attributed to a transition from the conduction band to



FIG. 2. (Color online) (a) XRD 2θ - θ pattern of the stoichiometric SrNbO₃ epitaxial thin film. The inset shows the pattern near the 002 peak taken with a high-resolution detector. (b) XRD reciprocal-space map image around the 103 diffractions of the SrNbO₃ thin film and KTaO₃ substrate. (c) Absorption coefficient spectrum of the stoichiometric SrNbO₃ thin film. The dashed line is a fit to the simple Drude model, using the carrier density evaluated by a Hall measurement. The inset shows a Tauc plot that assumes an indirect band gap.

a higher-level unoccupied band [10]. On the other hand, the NIR absorption is certainly derived from the high density of electrons, discussed later. The shape of the spectrum in the NIR region was not reproduced well with a simple Drude model [dashed line in Fig. 2(c)], suggesting considerable electron correlation. An extended Drude model may be necessary to explain the spectrum, similar to the case in other electron correlated systems such as Sr_2RuO_4 [21].

Figure 3 compares the resistivity, carrier (electron) density, and mobility measured at 300 K from SrNbO₃ thin films grown at various temperatures. The stoichiometric SrNbO₃ epitaxial thin film exhibited the minimum resistivity [Fig. 3(a)], and its carrier density agreed with the nominal value assuming that each Nb ion supplies one electron [dashed line in Fig. 3(b)]. Notably, the minimum resistivity of the stoichiometric SrNbO3 is $2.82 \times 10^{-5} \,\Omega$ cm, which is one order of magnitude lower than previously reported values [10,11]. As the growth temperature deviated from the optimal value, the resistivity drastically increased, probably owing to the off-stoichiometry mentioned previously: Excess oxygen layers introduced at lower growth temperatures compensate the electron carriers and suppress their mobility by breaking up the NbO₆ octahedral network. At higher growth temperatures, though, other defects are generated, such as Nb vacancies and Sr substitutions in the B site [20], both of which increase the Nb valence from 4+ to 5+ and thus decrease the carrier density.



FIG. 3. (Color online) Growth temperature dependence of (a) resistivity ρ , (b) carrier density *n*, and (c) Hall mobility μ of the SrNbO₃ thin films measured at room temperature. The dashed line in (b) indicates the nominal carrier concentration.

Figure 4 plots the resistivity and mobility of the stoichiometric SrNbO₃ epitaxial thin film as functions of temperature. The resistivity exhibited a metallic temperature dependence $(d\rho/dT > 0)$ from room temperature to 2 K. The mobility tended to increase with decreasing temperature and reached over 100 cm² V⁻¹ s⁻¹ at around 20 K. Tomio *et al.* investigated the transport properties of an SrNbO₃ thin film grown on an SrTiO₃ substrate and found resistivities of $1 \times 10^{-6} \Omega$ cm



FIG. 4. (Color online) Temperature dependence of the (a) resistivity and (b) Hall mobility of the stoichiometric SrNbO₃ epitaxial thin film. The inset in (a) shows the resistivity plotted against T^2 . The dashed line is a linear fit of the curve in the low-temperature region.

at 40 K and $2.7 \times 10^{-4} \Omega$ cm at 300 K [11]. The former resistivity is about one order of magnitude lower than that of our film, while the latter is about one order of magnitude higher than ours (Fig. 4). One possible explanation for this discrepancy is that the SrTiO₃ substrate used by Tomio *et al.* contributed greatly to the electrical conduction, particularly at low temperatures, owing to Nb interdiffusion at the film/substrate interface, the formation of oxygen vacancies, or both. In contrast, the KTaO₃ substrate in the present study does not show conductivity by Nb doping, and it requires much more reductive conditions to introduce oxygen vacancies. Thus, we believe that the transport data in Fig. 4 represent the intrinsic properties of SrNbO₃.

As shown in the inset of Fig. 4(a), the resistivity of SrNbO₃ at low temperatures follows the temperature dependence of $\rho = \rho_0 + AT^2$. Such a *T*-square dependence of ρ is observed in some metallic oxides and is usually attributed to the Fermi-liquid behavior of quasiparticles caused by electron correlation [14,22–28]. In order to verify this attribution in SrNbO₃, we compare the *T*-square coefficient *A*, which encapsulates the contribution of electron correlation to resistivity, with those of other Fermi-liquid perovskite oxides. Though Fermi-liquid materials have been widely investigated based on the Kadowaki-Woods rule, $A/\gamma^2 = \text{const}$ [29,30], where γ is the *T* linear coefficient of specific heat, the evaluation of γ is difficult for a thin film. Therefore, we propose another empirical relationship between *A* and conducting carrier density *n*. According to Ref. [31], *A* is expressed as follows,

$$A = \frac{4\pi^2 k_{\rm B}^2}{e^2 \hbar^2} \frac{m_{\rm b}}{n} \Phi, \tag{1}$$

where $k_{\rm B}$ is the Boltzmann constant, *e* is elementary charge, \hbar is the Planck constant divided by 2π , m_b is the band mass, which would be calculated using the localized density approximation, and Φ is the coefficient of the scattering rate $\Gamma(T,\omega) = \Gamma_0 + \Phi[(2\pi T)^2 + \omega^2]$. Thus, the factor $m_{\rm b}\Phi$ reflects band dispersion and many body effects in a correlated system. In Eq. (1), A is inversely proportional to n, assuming that $m_b \Phi$ is independent of n. Indeed, the ln A vs $\ln n$ plot for various Fermi-liquid perovskite oxides such as $SrTi_{1-r}Nb_rO_3$, $Sr_{1-r}La_rTiO_3$, $Ca_{1-r}Y_rTiO_3$, and $K_{1-x}Ba_xTaO_3$ shows the linear relationship with a slope of -1 [Fig. 5(a)]. Notably, all the plots are located on a single narrow band with a slope of -1, including other Fermi-liquid perovskite oxides such as $Ca_{1-r}Sr_rVO_3$ and $SrMoO_3$ [shaded area in Fig. 5(a)]. This fact empirically indicates that $m_{\rm b}\Phi$, i.e., prefactor of the 1/n, falls in a relatively narrow range in the case of Fermi-liquid perovskite oxides. Because A of the SrNbO₃ epitaxial thin film agrees well with this relationship, we considered that SrNbO3 is a Fermi-liquid material: In other words, electron correlation plays an important role in its electrical conduction. The non-Drude behavior observed in the NIR absorption of SrNbO₃ also supports this attribution.

For further discussion on the electron correlation in 3dand 4d transition-metal oxides, we compared the $m_b\Phi$ values of AMO_3 (A = Ca, Sr, M = V, Nb, Mo) in more detail. It is known that both band mass and electron correlation in perovskite oxides are affected by the structural distortion and size of the d orbital through the transfer integral. In order to extract the orbital-size contribution to $m_b\Phi$, we plotted



FIG. 5. (Color online) (a) Plot of the *T*-square coefficient *A* of resistivity vs carrier density *n* for single crystals or epitaxial films of perovskite-type transition-metal oxides [Sr_{1-x}La_xTiO₃ [22], SrTi_{1-x}Nb_xO₃ [23], K_{1-x}Ba_xTaO₃ [24], Ca_{1-x}Y_xTiO₃ [25], CaVO₃ [26], SrVO₃ [14], Ca_{1-x}Sr_xVO₃ [27], SrMoO₃ [28], and SrNbO₃ (this study)]. Dashed lines with a slope of -1 are drawn for several series of materials as guides for the eyes. The gray shaded area indicates the band with a slope of -1 from $m_b \Phi = 5 \times 10^{-52}$ to 2×10^{-50} kg s. (b) Plots of the $m_b \Phi$ value vs the tolerance factor for AMO_3 (A = Sr, Ca, M = V, Nb, Mo). Data are taken from the same references as (a). The tolerance factor was calculated from the ionic radius reported in Ref. [32].

 $m_b\Phi$ values of AMO_3 against the Goldschmidt's tolerance factor t [Fig. 5(b)]. It is known that smaller t increases the electron correlation in perovskite oxides through a decrease in the orbital overlap. This trend is confirmed by the plots of Ca_{1-x}Sr_xVO₃, where $m_b\Phi$ increases by decreasing t. On the other hand, $m_b\Phi$ values of SrNbO₃ and SrMoO₃ are clearly smaller than V-based perovskite oxides with similar t, indicating that the larger orbital of 4d transition metals leads to a smaller electron correlation and a smaller $m_b\Phi$ value. As a result of the balance between the structural distortion and orbital size, SrMO₃ (M = V, Nb, Mo) possesses a close $m_b\Phi$.

The *T*-square coefficient *A* also gives insight into the room-temperature resistivity of SrMO₃. The characteristic temperature T^* of SrNbO₃, the temperature at which its resistivity began to deviate from the parabolic relation described previously, was ~180 K [Fig. 4(a)], which is comparably high to that of SrMoO₃ [28]. Since such high T^* values make the second term in the equation $\rho = \rho_0 + AT^2$ dominant at high temperatures, the close *A* values of SrMO₃ (*M* = V, Nb, Mo) lead to a comparable resistivity of these materials at 300 K as long as the sample quality is good enough (Table I).

TABLE I. Resistivities at 300 K among $SrMO_3$ (M = V, Nb, Mo) as a bulk polycrystal, bulk single crystal, and epitaxial thin film.

Sample	ρ at 300 K ($\mu\Omega$ cm)		
	Polycrystal	Single crystal	Epitaxial thin film
$\overline{\text{SrNbO}_3(4d^1)}$	500 [10]		28 (present study)
$SrMoO_3 (4d^2)$		5.1 [25]	29 [33]
$SrVO_{3}(3d^{1})$	120 [34]	26 [13]	25 [14]

IV. CONCLUSION

We fabricated SrNbO₃ epitaxial thin films on a KTaO₃ substrate by PLD. We found that both the cation and anion compositions were very sensitive to growth temperature and that almost stoichiometric SrNbO₃ could be obtained at an optimum growth temperature of 630 °C. The stoichiometric SrNbO₃ film showed a room-temperature resistivity of $2.82 \times 10^{-5} \Omega$ cm, which is one order of magnitude lower than previously reported values and comparable with those of $3d^1$ SrVO₃ and $4d^2$ SrMoO₃. This result did not agree with a

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naive expectation that SrNbO₃ would show lower resistivity than SrVO₃ and SrMoO₃ because Nb⁴⁺ has the largest *d* orbital among these three materials. Based on the Fermi-liquid behavior of the low-temperature resistivity and the non-Drude feature of the NIR absorption, we inferred that electron correlation plays a significant role in the electrical conduction of SrNbO₃. A comparison of the *T*-square coefficient *A* of 3*d* and 4*d* perovskite oxides revealed an orbital-size contribution to the electron correlation in these materials.

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